Toluene CMOS





Material No.: 9466-03 Batch No.: 0000046562 Manufactured Date: 2013/04/04 Retest Date: 2018/04/03

Certificate of Analysis

| Test | Specification | Result |
|-----------------------------------|---------------|---------|
| Assay (C6H5CH3) (by GC) | >= 99.5 % | 99.9 |
| Color (APHA) | <= 10 | 5 |
| Acidity (µeq/g) | <= 0.2 | < 0.1 |
| Residue after Evaporation | <= 2.0 ppm | < 1.0 |
| Vater (by KF, coulometric) | <= 0.03 % | 0.01 |
| Substances Darkened by H2SO4 | Passes Test | РТ |
| Sulfur Compounds (as S) | <= 0.003 % | < 0.001 |
| Chloride (Cl) | <= 2 ppm | < 2 |
| Phosphate (PO4) | <= 0.5 ppm | < 0.5 |
| Frace Impurities – Aluminum (Al) | <= 20.0 ppb | < 5.0 |
| Arsenic and Antimony (as As) | <= 10 ppb | < 10 |
| race Impurities – Barium (Ba) | <= 10.0 ppb | < 1.0 |
| race Impurities – Boron (B) | <= 20.0 ppb | < 5.0 |
| race Impurities – Cadmium (Cd) | <= 20.0 ppb | < 1.0 |
| race Impurities – Calcium (Ca) | <= 100.0 ppb | 2.3 |
| Frace Impurities – Chromium (Cr) | <= 10.0 ppb | < 1.0 |
| Frace Impurities – Cobalt (Co) | <= 20.0 ppb | < 1.0 |
| Frace Impurities – Copper (Cu) | <= 20.0 ppb | < 1.0 |
| Frace Impurities – Gallium (Ga) | <= 50.0 ppb | < 1.0 |
| Frace Impurities – Germanium (Ge) | <= 50.0 ppb | < 10.0 |
| race Impurities – Gold (Au) | <= 20.0 ppb | < 5.0 |
| ieavy Metals (as Pb) | <= 500 ppb | < 500 |
| Frace Impurities – Iron (Fe) | <= 20.0 ppb | < 1.0 |
| Trace Impurities – Lithium (Li) | <= 20.0 ppb | < 1.0 |

For questions on this Certificate of Analysis please contact Technical Services at 855.282.6867 or +1.610.573.2600 Avantor ™ Performance Materials Inc.

3477 Corporate Parkway. Suite #200. Center Valley, PA 18034. U.S.A. Phone: 610.573.2600 . Fax: 610.573.2610

| Test | Specification | Result |
|-------------------------------------|---------------|--------|
| Trace Impurities – Magnesium (Mg) | <= 10.0 ppb | < 1.0 |
| Trace Impurities – Manganese (Mn) | <= 10.0 ppb | < 1.0 |
| Trace Impurities – Nickel (Ni) | <= 20.0 ppb | < 5.0 |
| Trace Impurities – Potassium (K) | <= 50.0 ppb | < 10.0 |
| Trace Impurities – Silicon (Si) | <= 100.0 ppb | < 10.0 |
| Trace Impurities – Silver (Ag) | <= 20.0 ppb | < 1.0 |
| Trace Impurities – Sodium (Na) | <= 100.0 ppb | < 5.0 |
| Trace Impurities – Strontium (Sr) | <= 10.0 ppb | < 1.0 |
| Trace Impurities – Tin (Sn) | <= 30.0 ppb | < 10.0 |
| Trace Impurities – Zinc (Zn) | <= 20.0 ppb | < 1.0 |
| Particle Count – 1.0 µm and greater | <= 10 par/ml | < 10 |

For Microelectronic Use

Country of Origin: US Packaging Site: Paris Mfg Ctr & DC



Phillipsburg, NJ 9001:2008, 14001:2004 Paris, KY 9001:2008 Mexico City, Mexico 9001:2008 Deventer, The Netherlands 9001:2008, 14001:2004, 13485:2003 Gliwice, Poland 9001:2008, 17025:2005 Selangor, Malaysia 9001:2008 Dehradun, India, 9001:2008, 14001:2004, 13485:2003 Mumbai, India, 9001:2008, 17025:2005 Panoli, India 9001:2008

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Richard M Siberski Global Director of Quality Assurance

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